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Kinetics of $(2\times4)\rightarrow(3\times1(6))$ structural changes on GaAs(001) surfaces during the UHV annealing

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Highlights

- The transition of GaAs(001) surface from state $\alpha(2\times4)$ into state $(3\times1(6))$ is a complex process involving two transitions, $\alpha(2\times4) \to DO$ and $DO \to (3\times1(6))$.
- The transitions $\alpha(2\times4) \to DO$ and $DO \to (3\times1(6))$ feature a fixed number of domains over the whole transition process.
- Activation energies of respectively $3.44 \pm 0.08 \text{ eV}$ and $3.73 \pm 0.09 \text{ eV}$ were obtained for these transitions.
- The procedure for precise determination of GaAs(001) surface temperature using the features of the $\alpha(2\times4) \rightarrow DO$ transition process kinetic was proposed.



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